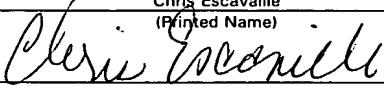
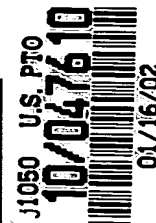


IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Babcock et al.
Title: Phase-Shifting Mask With
Trenches Having Multiple Depths
Appl. No.: Unknown
Filing Date: Unknown
Examiner: Unknown
Art Unit: Unknown

CERTIFICATE OF EXPRESS MAILING	
I hereby certify that this correspondence is being deposited with the United States Postal Service's "Express Mail Post Office To Addressee" service under 37 C.F.R. § 1.10 on the date indicated below and is addressed to: Commissioner for Patents, Washington, D.C. 20231.	
EL716378315US (Express Mail Label Number)	January 16, 2002 (Date of Deposit)
Chris Escaville (Printed Name)	
 (Signature)	



INFORMATION DISCLOSURE STATEMENT

Commissioner for Patents
Box PATENT APPLICATION
Washington, D.C. 20231

Sir:

Pursuant to 37 C.F.R. §§ 1.97-98 and in accordance with the duty of disclosure under 37 C.F.R. §1.56, Applicant submits herewith the references listed on the attached Form PTO-1449 to the Examiner such that they may be considered and made of record in the above-identified application. A copy of each reference is enclosed.

Applicant also brings to the Examiner's attention the following related application:

U.S. Appl. No. 09/776,242 entitled "Binary and Attenuating Phase-Shifting Masks for Multiple Wavelengths", filed February 2, 2001, by Ghandehari et al. (Atty. Dkt. No. 39153/328).

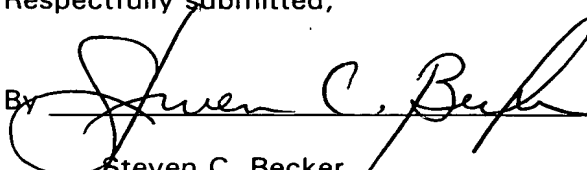
A copy of the application is enclosed pursuant to 37 C.F.R. § 1.98(a)(2)(iii).

Respectfully submitted,

Date

1/16/02
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By


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